	Application No. Applicant(s) 10/720,372 GHIRON ET AL.		
Notice of Allowability			
	Examiner	Art Unit	
	Jerry T Rahll	2874	
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.31	(OR REMAINS) CLOSED in or other appropriate commestights. This application is	n this application. If not inclu- junication will be mailed in due	ded e course. THIS
1. This communication is responsive to			
2. X The allowed claim(s) is/are <u>1-46</u> .			
3. The drawings filed on 11 May 2004 are accepted by the E	xaminer.		
 4. ☐ Acknowledgment is made of a claim for foreign priority u a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents hav 2. ☐ Certified copies of the priority documents hav 3. ☐ Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	e been received. e been received in Application	on No	ation from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file MENT of this application.	e a reply complying with the re	equirements
 A SUBSTITUTE OATH OR DECLARATION must be subn INFORMAL PATENT APPLICATION (PTO-152) which giv 	nitted. Note the attached EX es reason(s) why the oath o	AMINER'S AMENDMENT or or declaration is deficient.	NOTICE OF
 CORRECTED DRAWINGS (as "replacement sheets") mu (a) ☐ including changes required by the Notice of Draftsper 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner Paper No./Mail Date 	son's Patent Drawing Revie		
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in	l.84(c)) should be written on t the header according to 37 Cl	the drawings in the front (not th FR 1.121(d).	ne back) of
 DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT 	osit of BIOLOGICAL MAT FOR THE DEPOSIT OF BIO	ERIAL must be submitted. OLOGICAL MATERIAL.	Note the
Attachment(s)	_		
 Notice of References Cited (PTO-892) D Notice of Draftperson's Patent Drawing Review (PTO-948) 		nformal Patent Application (PT	ГО-152)
	Paper No.	Summary (PTO-413), /Mail Date	
 Information Disclosure Statements (PTO-1449 or PTO/SB/ Paper No./Mail Date <u>2/26/04</u> 		Amendment/Comment	
 Examiner's Comment Regarding Requirement for Deposit of Biological Material 	8. ⊠ Examiner's 9. □ Other	Statement of Reasons for Al	lowance
of biological Material	Aulla	—' ., yerry T Rahll ∥//	her
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Examiner's Statement of Reasons for Allowance

Drawings

1. The drawings submitted on 11 May 2004 have been reviewed and determined to facilitate

Information Disclosure Statement

2. The information disclosure statement (IDS) submitted on 26 February 2004 is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure

statement is being considered by the examiner (note attached form PTO-1449).

understanding of the invention. The drawings are accepted as submitted.

Allowable Subject Matter

3. The following is an examiner's statement of reasons for allowance. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

4. Claims 1-46 are allowed. Claims 1-46 describe an optical coupling arrangement having a silicon waveguide formed in a surface layer of a SOI wafer, a prism coupler attached to the SOI wafer such that a first surface of the prism coupler is parallel and mated to a flat surface of the SOI wafer, and where the refractive index of the prism coupler is equal to or greater than that of the waveguide, optical elements to collimate, shape and steer an optical input beam, an evanescent coupling region between the prism coupler and the waveguide and output elements in the path of the beam that emerges from the output surface of the prism coupler to shape, collimate or steer the optical beam.

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5. U.S. Patent No. 3,586,872 to Tien describes an optical coupling arrangement having a waveguide formed in a surface layer of a wafer, a prism coupler attached to the wafer such that a first surface of the prism coupler is parallel and mated to a flat surface of the wafer, optical elements to collimate, shape and steer an optical input beam and an evanescent coupling region between the prism coupler and the waveguide. Tien does not describe the waveguide as a silicon waveguide formed on the surface layer of an SOI wafer. Further, Tien does not describe the refractive index of the prism coupler is equal to or greater than that of the waveguide. Further, Tien does not describe output elements in the path of the beam that emerges from the output surface of the prism coupler to shape, collimate or steer the optical beam.

6. U.S. Patent No. 3,586,872 to Tien remains the closest prior art of record in this application. For the reasons stated above, however, Claims 1-46 herein are deemed to patentably distinguish over Tien and all other prior art of record.

Conclusion

7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. U.S. Patents Nos. 4,152,045, 4,832,428, 6,219,475 and 6,526,187 describe optical coupling arrangements having waveguides and prism couplers

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jerry T Rahll whose telephone number is (571) 272-2356. The examiner can normally be reached on M-F (8:00-5:30), with alternate Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Rodney Bovernick can be reached on (571) 272-2344. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jerry T Rahll

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